



Dielectric Properties of Samarium Doped-Sodium Potassium Niobate Thin Films



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Abstract

This short communication revealed the importance of Samarium, Sm as a dopant in Sodium Potassium Niobate, KNN thin films. It was found that the surface roughness of about 1.583nm was reduced with Sm doping. Furthermore, the microstructure of doping films was more uniform in term of size and shape. This also led to the improvement of dielectric properties.

Keywords: KNN, Sm, Thin films, Doping

Introduction

For the past 10 years, ferroelectric ceramics with a perovskite structure, a tungsten bronze structure, and bismuth layer-structured (BLSF) have been reported to replace the lead-based materials. Recently, more findings with better results has been reported from various perovskite-structured ferroelectrics such as barium titanate (BaTiO_3 (BT)), bismuth titanate ($(\text{Bi}_{1/2}\text{Na}_{1/2})\text{TiO}_3$ (BNT)), bismuth sodium titanate ($(\text{Bi}_{1/2}\text{K}_{1/2})\text{TiO}_3$ (BKT)), potassium niobate (KNbO_3 (KN)), sodium potassium niobate ($(\text{K, Na})\text{NbO}_3$ (KNN)) [1]. Among these, KNN has been nominated as one of the most promising candidates to replace the wide usage of lead-based materials especially the lead zirconate titanate ($\text{Pb}[\text{Zr}_x\text{Ti}_{1-x}]\text{O}_3$). KNN is a combination of solid solution ferroelectric KNbO_3 and anti-ferroelectric NaNbO_3 that has been the most studied lead-free piezoceramics materials due to its relatively high piezoelectric constant (416 pC/N) and high Curie temperature (420 °C) [2-4].

The formation of KNN structure has some lacking due to oxygen vacancies and some intrinsic defects. Therefore, many researches have been done in substituting the vacancies with rare-earth and researchers still trying to find the ideal dopant to be doped into the KNN structure. Different dopants will give different effects to the materials. However, not all dopants are suitable for certain applications. In our current work, samarium (Sm) was introduced into KNN structure in order to overcome the intrinsic defects. Samarium is a member of lanthanide series with an oxidation state of +3, atomic radii of 1.81 Å and ionic radii of 0.964 Å, was chosen as a doping element due to its stability of perovskite phase, ionic radius and the Curie-Weiss temperature [5].

Research Methodology

The experiment was divided into precursor preparation, deposition and annealing process and followed by analysis. The precursor was started by dissolving CH_3COOK and CH_3COONa into 2-ME in a beaker with constant stirring at room temperature. $\text{Nb}_2(\text{OC}_2\text{H}_5)_{10}$ was also prepared with a constant stirring at room temperature in another beaker containing 2-ME with the addition of acetylacetone. Later on, both of the precursors were mixed together for another constant stirring at 60 °C for an hour. The same steps were repeated for the doping precursor, where the samarium with different concentrations was added to the beaker containing CH_3COOK and CH_3COONa . After that, the deposition process was done by depositing the precursor onto the silicon (Si) substrate for five layers. Spin coater had been used in order to deposit the layers. One minute of pyrolysis was taking place between each of the layers. To end the deposition process, the wet films were annealed at 650 °C for 10 minutes by using the rapid thermal processing (RTP) furnace. The samples were ready to be characterized and analysed.

Result and Discussions

The 3D AFM surface topography micrographs for both samples are shown in Figure 1. The scanned area of 1m x 1µm came out with roughness, R_q of 1.658nm for KNN films (Figure 1a) while 1.583m for Sm doping (Figure 1b). The integration of Sm as a dopant into KNN structure helps to minimize the roughness of thin films. Furthermore, the microstructure of KNN with Sm doping is more uniform in term of size and shape as compared to that of KNN.

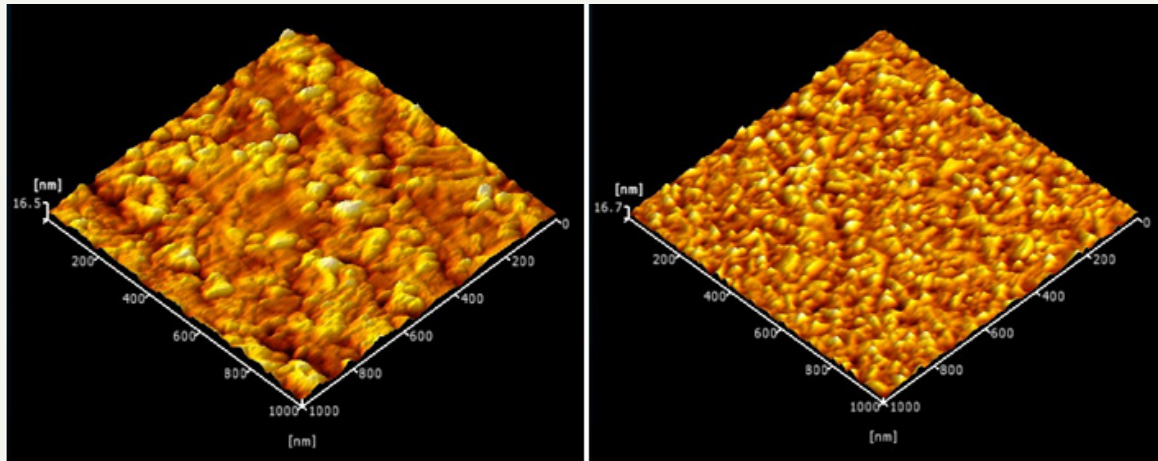


Figure 1: 3D AFM topography micrographs of:
1a: KNN and
1b: Sm-KNN thin films.

Table 1: Dielectric properties measured at 1kv.

	KNN	Sm-KNN
Dielectric constant	366	570
Dielectric loss	0.00211	0.00108

Table 1 shows the dielectric properties of both thin films measured at 1kV. The incorporation of Sm into KNN shows a significant result in term of electrical properties. As seen, the dielectric constant and dielectric loss of Sm-KNN were greatly improved with 36% and 49%, respectively as compared to that of KNN thin films. This improvement is in line with the uniformity of microstructure as shown clearly in Figure 1b. It is well to be said that the incorporation of Sm into KNN might be useful for fabricating this material into microelectronic devices with better dielectric properties. Further studies on the other analyses will be reported in order to have a good conclusion on this research.

Conclusion

Initial study on the comparison of KNN and Sm doped- KNN thin films were successfully carried out in this work. It was clearly

seen that the improvement on surface roughness with uniform microstructure shown by the films with Sm doping, thus leading to a significant result on dielectric properties.

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